**Electronic Supplementary Information (ESI) for:** 

# Soft Nano Wrapping on Graphene Oxide by Metal-organic Network Composed of Tannic Acid and Fe Ions

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#### Experimental

All starting materials and reagents were purchased from commercial suppliers and used without further purification. The graphite flake (natural, -325 mesh, 99.8%) was also purchased from Alfa Aesar and used as received. Ultraviolet–visible spectroscopy (UV-Vis) absorption and Raman spectra were recorded on an Agilent 8453 UV-Vis spectrophotometer and Lambda Vision MicroRAM-200 spectrometer, respectively. Zeta potential measurements were conducted by Otsuka electronics ELSZ-1000ZS. FT-IR spectra were recorded on an JASCO FT/IR-4200 FT-IR Spectrometer. Thermogravimetry (TG) analysis was carried out by RIGAKU Thermo plus EVO2 with a heating rate of 5°C/min in a N<sub>2</sub> atmosphere. X-ray photoelectron spectroscopy (XPS) analysis was carried out using a Kratos-Shimazu AXIS HIS-165. Atomic force microscopy (AFM) images of the samples were recorded using an Agilent 5500. SEM images and energy-dispersive X-ray spectroscopy elemental mapping were observed using a field-emission type scanning electron microscopy (SEM) (S-5500, Hitachi High-Technologies) operated at 5 kV. Transmission electron microscopy (TEM) images were observed using Hitachi HT 7700 operated at 100 kV.

#### Preparation of graphene oxide

Graphene oxide (GO) was prepared according to the modified Hummers method.<sup>1</sup>

#### Fabrication of TA-Fe/GO sheet in water

Graphene oxide (1.5 mg) and tannic acid (TA) (4mg) were added to 10 ml of water, and the mixture was sonicated for 2 min. FeCl<sub>3</sub>· $6H_2O$  (2mg) was added to the mixture solution and stirred for 1 min. The suspension was centrifuged (1000 G, 5 min) and the supernatant was removed to remove the excess TA, Fe ions, and TA-Fe complex which were not used for the wrapping on GO surface. The remaining solid was washed with water and centrifuged (1000 G, 5 min). The obtained solid was dispersed into 10 ml of water by sonication.

### Reduction of TA-Fe/GO sheets by hydrazine vapor

The TA-Fe/GO sheet on glass or silicon substrates were placed in a Petri dish containing 5 mL of hydrazine monohydrate. The substrate in the petri dish was heated to 100°C for 1 h. The obtained sheets were rinsed with MeOH and dried under air. The TA-Fe/GO sheets changed color after hydrazine vapor treatment, from dark gray to metallic gray, indicating reduction of the material.



Figure S1. UV-Vis absorption spectra of TA-Fe/GO sheets in aqueous solution under neutral (solid line), basic (dotted line, addition of 1N NaOHaq), and acidic (broken line, addition of the HCl) conditions.



Figure S2. SEM image of TA-Fe/GO sheet on silicon substrate.



Figure S3. (a) AFM image and (b) cross section analysis of GO sheet.



Figure S4. FT-IR spectra of GO (dotted line), TA-Fe/GO (solid line), and TA (broken line) in KBr pellet.



Figure S5. Raman spectra of TA-Fe/GO (solid line) and GO (dotted line) on silicon substrate.



Figure S6. XPS spectra of TA-Fe/GO sheets.



Figure S7. XPS of C1s spectra of GO. Deconvolution curves are also shown.



Figure S8. UV-Vis absorption spectra of TA-Fe/GO (solid line) and TA-Fe/rGO (broken line) sheets on quartz substrate.



Figure S9. Raman spectrum of TA-Fe films on a silicon substrate.



Figure S10. XPS spectra of TA-Fe/rGO sheets on silicon substrates. Peak at 399.9 eV corresponds to hydrazine. N 1s peak derived from residual hydrazine and reacted GO with hydrazine.



Figure S11. The ratios of both intensities between  $I(Fe 2p_{3/2})$  and I(C1s) of TA-Fe/GO before (left) and after (right) reduction.



Figure S12. TGA curves of TA-Fe/rGO (solid line), TA-Fe/GO (dotted line), and GO (broken line) sheets with heating rate of 5°C/min in nitrogen gas atmosphere.

## References

1. D. C. Marcano, D. V. Kosynkin, J. M. Berlin, A. Sinitskii, Z. Sun, A. Slesarev, L. B. Alemany, W. Lu and J. M. Tour, *ACS Nano*, **2010**, *4*, 4806-4814.